

Title (en)

METHOD FOR ETCHING A PATTERN ON A COATING DEPOSITED ON A SUBSTRATE; CORRESPONDING SUBSTRATE

Title (de)

VERFAHREN ZUM ÄTZEN EINES MUSTERS AUF EINER AUF EINEM SUBSTRAT ABGESCHIEDENEN BESCHICHTUNG; ENTSPRECHENDES SUBSTRAT

Title (fr)

PROCÉDÉ DE GRAVURE D'UN MOTIF SUR UN REVÊTEMENT DÉPOSÉ SUR UN SUBSTRAT; SUBSTRAT CORRESPONDANT

Publication

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Application

EP 20848862 A 20201218

Priority

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Abstract (en)

[origin: WO2021123690A1] The present invention relates to a method for processing a coating on a substrate passing through a processing unit generating a laser beam, said method consisting in producing a pattern having a plurality of lines or portions extending in the direction of travel and/or the direction orthogonal to the direction of travel, said pattern being repeated to cover and process the surface of the substrate.

IPC 8 full level

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CPC (source: EP US)

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See references of WO 2021123690A1

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